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(54) **Ball grid array arrangement**

(57) A ball grid array arrangement comprises a multilayer cofired ceramic or PCB-type substrate 12, on a lower metallisation layer of which is disposed an array of solder balls 22, a central group of which solder balls 22 serves to provide grounding for a lower ground plane and a die-attach ground plane 13 on the upper surface of the substrate. One or more passive components are integrated into the substrate 12: e.g. a transmission-line resonator or interdigitated filter is integrated into an inner metallisation layer in the central part of the BGA arrangement between adjacent rows of solder balls, or a spiral inductor is integrated into the upper metallisation layer in the corners of the substrate between neighbouring groups of wire-bond pads 19, 20, which are provided for the mounting of a multichip module 24 to the BGA arrangement. Screening is provided by an electrically conductive lid 21.

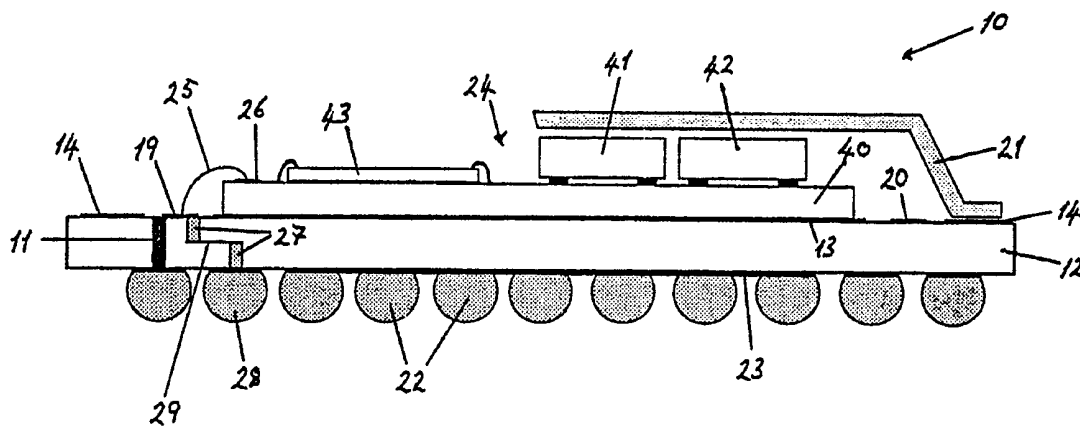


Figure 2

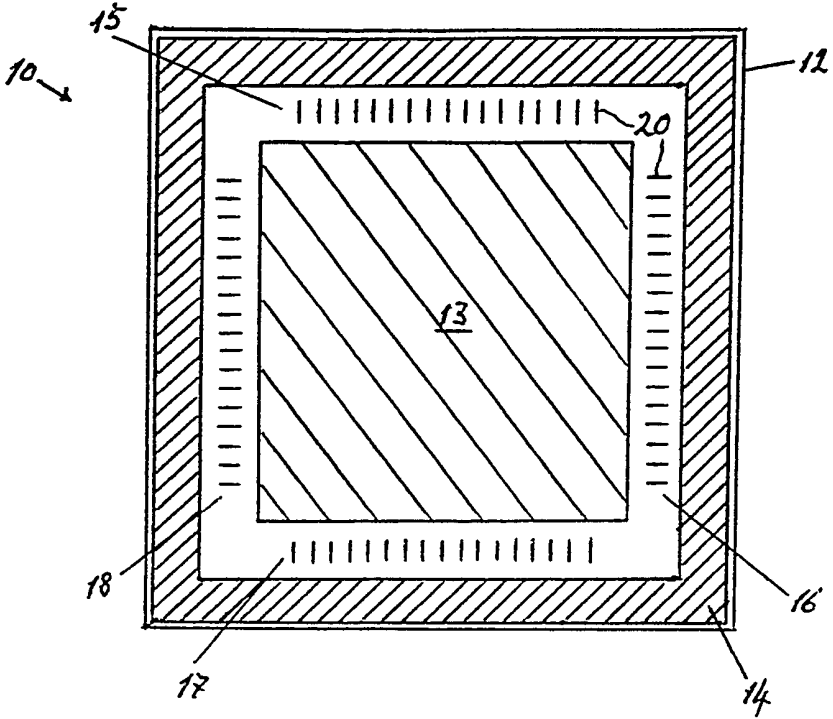


Figure 1

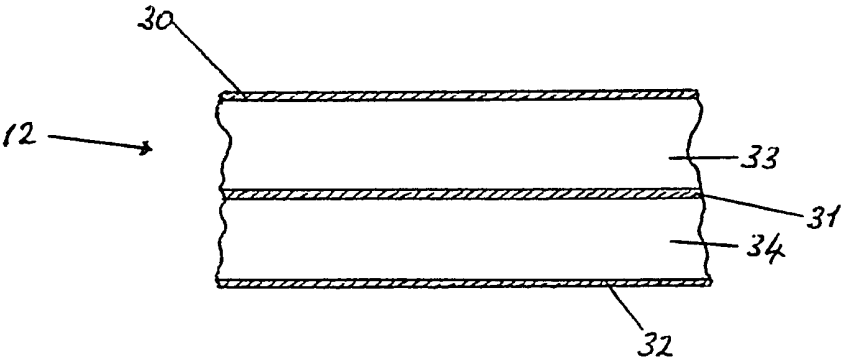


Figure 3

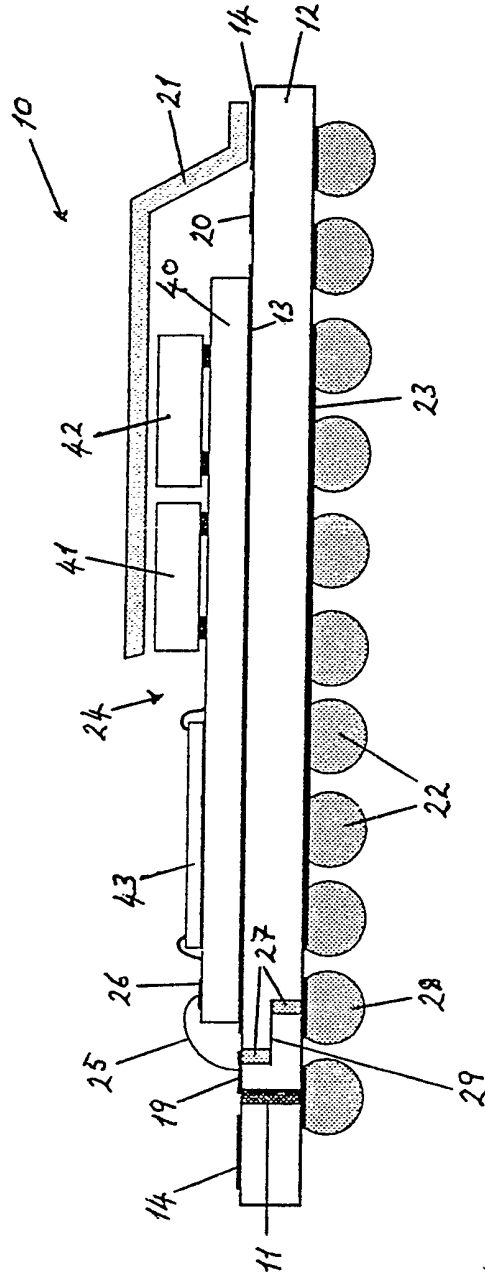


Figure 2

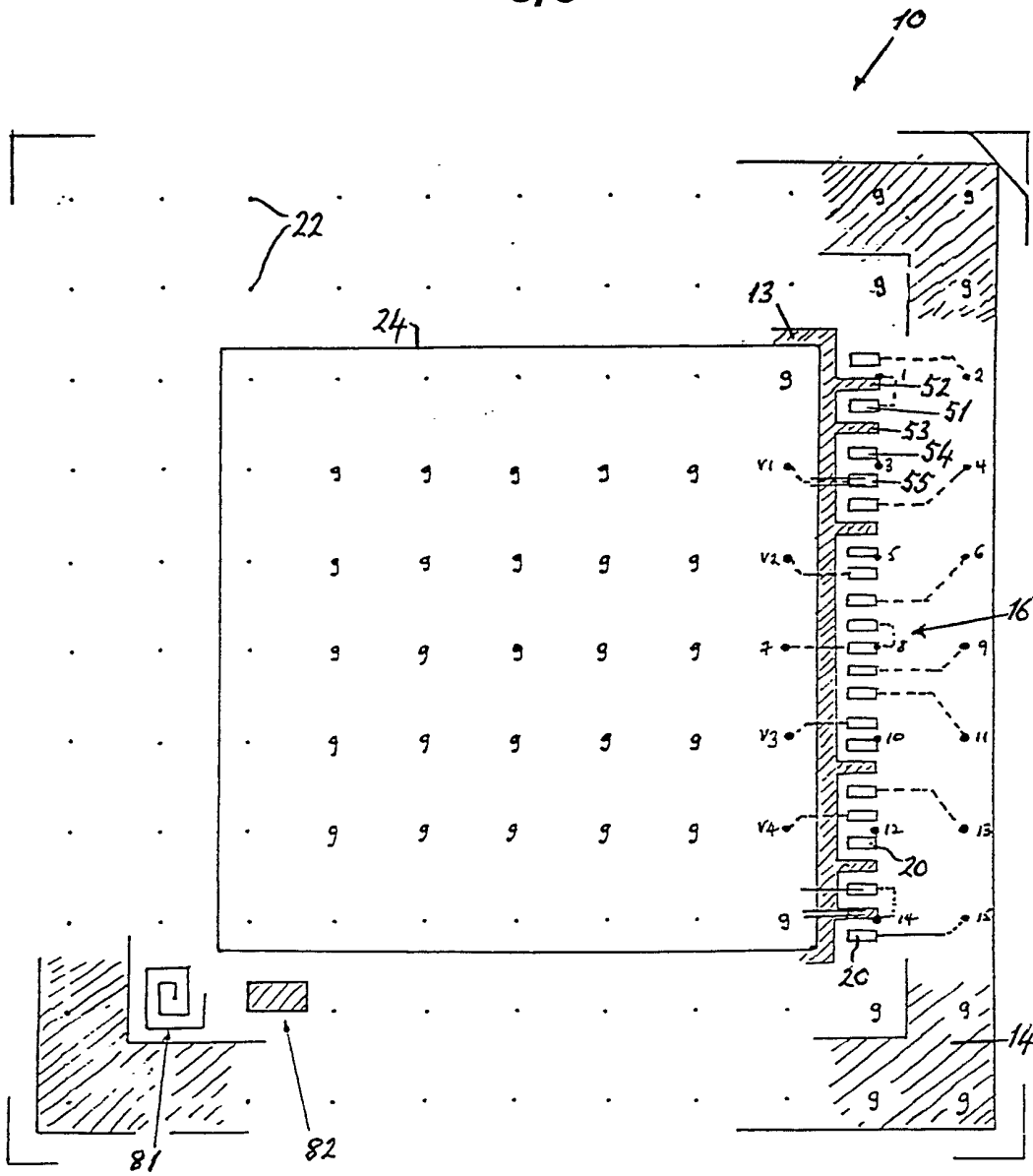


Figure 4

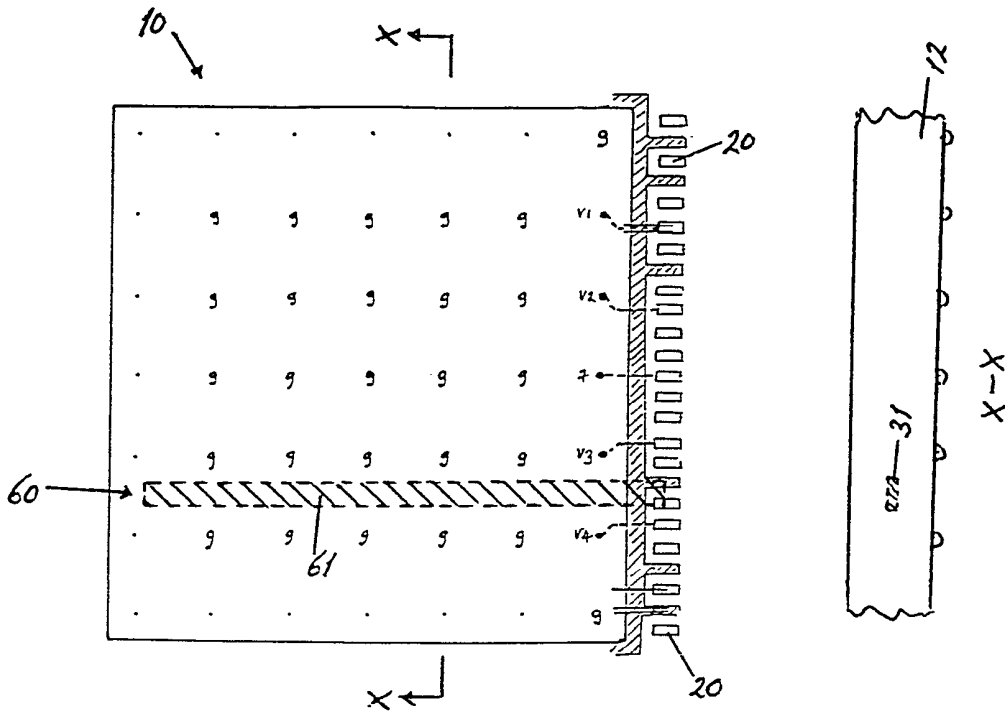


Figure 5

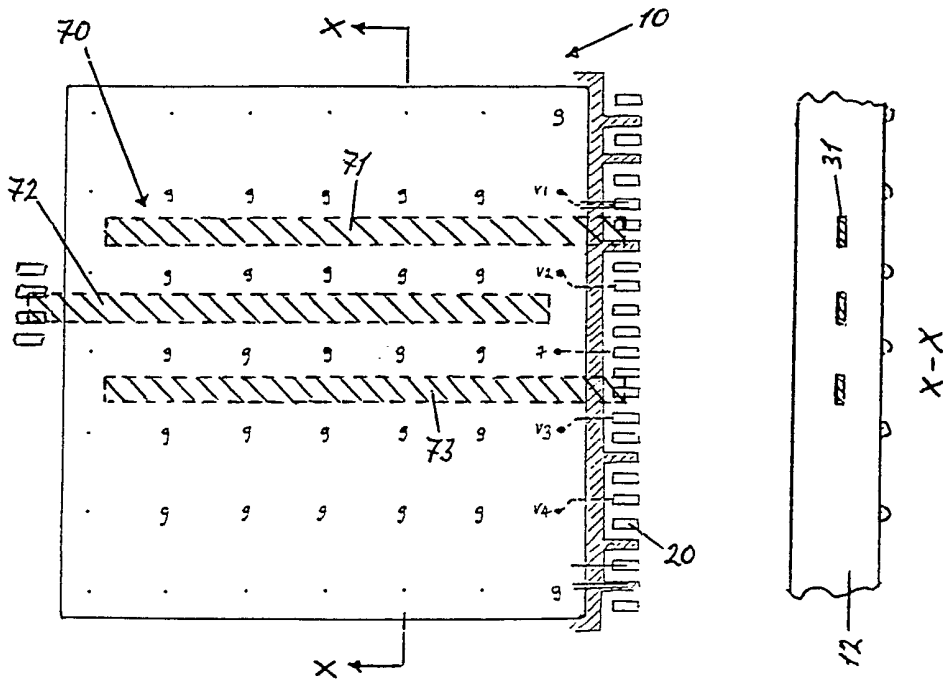


Figure 6

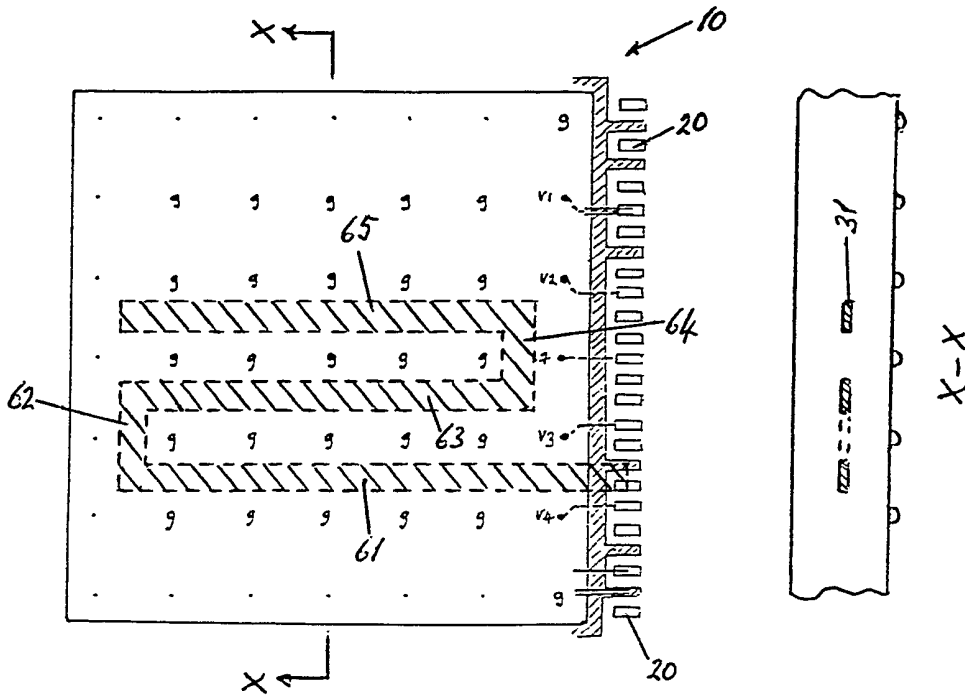


Figure 7

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BALL GRID ARRAY ARRANGEMENT

The invention concerns a ball grid array arrangement, and in particular, but not exclusively, a ball grid array arrangement for enabling the connection of a multichip module to other circuitry.

5 There is a growing requirement, in the construction of very compact, low-cost radios and other rf communications circuits, for small, high performance and cost-effective package components.

In the case of radios and related products that employ mixed-technology silicon integrated circuit and GaAs monolithic microwave integrated circuit devices supported
10 on multichip module MCM-D substrate structures incorporating integrated passive components, the very significant reduction in the physical size of the product in comparison with conventional surface-mount assemblies has led to a requirement to provide a large number of connections from the module package to the surrounding
15 ground connections may be required from a multichip module (MCM) assembly in which the substrate is only 10mm square.

In addition, the high-frequency nature of these products demands highly effective
20 grounding for the MCM-D substrate and its mounted microwave GaAs and high-speed silicon active devices, together with low-inductance supply connections and very short, low-inductance external signal connections. Further, a very high level of isolation is also commonly required between specific external package connections or ports.

There is also a need to be able to test an assembled multichip radio module. Ball grid array (BGA) packaging arrangements exist which were developed to house high-speed (~ 50 MHz clock rate, or higher), high-pin-count, digital silicon ASICs (application-specific ICs) and related silicon IC devices within a compact package footprint. The BGA packages are constructed using a cofired ceramic technology with refractory metallisation systems (e.g. tungsten) and an alumina (or aluminium nitride) dielectric material, or by printed-circuit-board-like methods using plated copper metallisation with organic composite laminate materials. The package base supports an area array of solderable metallisation pads, each of which is provided with a solder ball connection. A multilayer package base construction is employed, with up to eight layers of metallisation and appropriate interlayer vias, to provide the dense routing demanded between the solder pad connections on the package base and rows of wire bond pads located on the upper surface of the package. A solderable seal ring metallisation may be provided around the perimeter of the package upper surface. The assembled package may then be completed by the sealing of a metallic lid structure or by encapsulation or moulding with a suitable filled or unfilled organic material.

The invention aims to provide a packaging arrangement which attempts to fulfil at least some of the requirements mentioned at the outset by suitable adaptation of the known ball grid array arrangement.

In accordance with a first aspect of the invention, there is provided a ball grid array arrangement, comprising a dielectric multilayer substrate having an upper, a lower and at least one inner layer of metallisation, the lower metallisation layer

including an array of solder balls, the substrate having also a central, die-attach area for the mounting of at least one chip or multichip module, and a peripheral area containing bonding structures for establishing electrical connections between at least some of the solder balls and the at least one chip or chip module, the ball grid array
5 arrangement including a passive circuit element integrated into at least one of the metallisation layers.

The integration of a passive circuit element into the BGA arrangement has the advantage of allowing the characteristics of various circuitry within the chip or multichip module to be trimmed on the BGA arrangement itself, thereby permitting a
10 degree of chip or module testing to be carried out before the BGA arrangement is made part of further circuitry.

The passive circuit element may be formed in the upper or at least one inner metallisation layer within the central area between adjacent rows of solder balls. The
passive circuit element may be a line resonator, or an interdigitated filter, formed in
15 the at least one inner metallisation layer and defined by that layer in conjunction with adjacent metallisation layers and intervening dielectric layers.

The line resonator, or interdigitated filter, transmission line structure is advantageously terminated by a microstrip section formed in the upper or lower metallisation layer, the microstrip section serving to provide an exposed region of
20 metallisation that can be selectively removed to trim the electrical response of the resonator or filter.

The use of a short surface microstrip section in this way allows the manufacturing tolerances that arise due to shrinkage in the dimensions of a ceramic substrate during co-firing to be corrected for.

The peripheral area may include at least two groups of bonding structures, the
5 passive circuit element being disposed in the peripheral area between adjacent groups
of bonding structures. The passive circuit element may be an inductor, which is
preferably defined in the upper metallisation layer. By integrating an inductor into the
upper metallisation layer, advantage can be taken of the higher conductivity of that
layer, vis-à-vis the inner layer or layers, to ensure a high Q-factor in the component,
10 and of the increased spacing relative to the lower metallisation layer to ensure low stray
capacitance and therefore high self-resonance frequency.

A capacitor may be mounted adjacent to the inductor for providing a tuning
function for circuitry within the chip or multichip module mounted on the ball grid
array arrangement.

15 The ball grid array arrangement may include ground planes formed in the upper
and lower metallisation layers in the central area, at least some of the solder balls in
the lower metallisation layer in the central area being allocated as common ground
connections for the ground planes. The upper ground plane may be a die-attach plane
upon which the chip or multichip module is to be mounted.

20 A seal ring may be disposed around the outer part of the peripheral area of the
BGA substrate, the seal ring serving as a bonding structure for bonding a sealing cover
to the ball grid array arrangement. Use of a sealing cover, which is preferably metal,

has the advantage, firstly, of protecting the BGA package from the ingress of dirt and moisture, and secondly, where the lid is metallic, of electrically screening the device from RF interference. The seal ring may be arranged to be grounded by means of solder balls in the lower metallisation layer.

5 The bonding structures in the peripheral area may be wire-bond pads formed in the upper metallisation layer, the pads being either signal pads or ground or power-supply pads, the pads being arranged so that at least some of the signal pads are each situated between ground or power-supply pads. The wire-bond pads may be disposed between the central ground plane in the upper metallisation layer and the peripheral
10 seal ring.

Arranging for at least some of the signal-carrying wire-bond pads to be situated between ground, or effective ground, pads (i.e. power supply pads) has the advantage of increasing the signal isolation between the signal pads.

According to a second aspect of the invention, there is provided a multichip
15 module assembly, including a ball grid array arrangement, as described above, and a multichip module mounted on the ball grid array arrangement.

According to a third aspect of the invention, there is provided a multichip module radio or communications device, including a multichip module assembly as described above.

20 The invention will now be described, by way of example only, with reference to the drawings, of which:

Figure 1 is a simplified plan view of a ball grid array arrangement according to first and second embodiments of the invention;

Figure 2 is a side elevation of a multichip module assembly incorporating a ball grid array arrangement according to first and second embodiments of the invention;

5 Figure 3 is a cross-section of a substrate used in a ball grid array arrangement according to first and second embodiments of the invention;

Figure 4 shows parts of the arrangement of Figure 1 in greater detail;

Figure 5 shows the incorporation of a quarter wave triplate resonator into the inner metallisation layer of a BGA according to a first embodiment of the invention;

10 Figure 6 shows the incorporation of an interdigitated triplate filter into the inner metallisation layer of a BGA according to a first embodiment of the invention, and

Figure 7 shows the incorporation of a quarter wave triplate resonator into the inner metallisation layer of a BGA according to a second embodiment of the invention.

Referring to Figures 1, 2 and 3, a simplified plan view of a ball grid array arrangement 10 according to a first embodiment of the invention is shown, comprising 15 a multilayer substrate 12, which consists of three metallisation layers 30, 31, 32 and two intervening dielectric layers 33, 34. In the upper metallisation layer 30 are formed a central die-attach pad 13 forming a ground plane, a peripheral seal ring 14 and four groups 15-18 of wire-bond pads 20. A central part of the lower metallisation layer 20 likewise contains a ground plane. The substrate 12 is constructed using a cofired ceramic technology with refractory metallisation systems such as tungsten or molybdenum and an alumina (or aluminium nitride) dielectric material. In this process,

the metallisation patterns are defined by screen-printing tungsten or molybdenum powder inks onto unfired Al_2O_3 layers in tape form. The tape comprises the powdered ceramic dielectric held together by an organic binder. When the patterns have been printed, the various layers of tape are laminated together and the resulting body fired
5 at between 1650 and 1900°C to remove the binders and to densify the structure.

The seal ring 14 allows an electrically conductive lid 21 to be bonded to the BGA, using either a gold-tin eutectic alloy composition or lower melting-point soft solder compositions, depending upon the thermal stability of the materials employed in the BGA package and the MCM.

10 The seal ring 14, the lower ground plane and the die-attach pad 13 are grounded by means of groups of solder balls 22 formed on the lower metallisation layer 32. Use of multiple solder balls in this way results in very low inductance grounding for the planes concerned. The wire-bond pads 20 are the means by which one or more chip dies or a multichip module (MCM) 24 is electrically connected to circuitry on a card
15 (not shown) onto which the BGA package 10 is mounted. Thus, connections are made between the MCM 24 and the solder balls 22 by wire bonds 25, which link wire-bond pads 26 on the MCM 24 to corresponding wire-bond pads 25 on the BGA substrate 12, and by traces defined in the inner metallisation layer 31. Connections between the pads 20 and the inner metallisation layer 31 and between the inner metallisation layer
20 31 and the solder balls 22 are made by metal-filled vias 11 formed in the dielectric layers 33, 34. Figure 2 shows one such connection between a pad 19 and a solder ball 28, the connection being made by means of two vias 27 and an inner trace 29.

The multichip module (MCM) 24 is a complete sub-circuit incorporating a number of chips bonded to a substrate 40. Figure 2 shows three such chips, namely two flip-chip silicon IC's 41, 42, which are bonded to the substrate 40 by way of solder bumps similar to, but of smaller scale than, the solder balls 22, and a GaAs chip 5 43 which is wire-bonded to the substrate 40.

A more detailed representation of the BGA package according to the invention is shown in plan view in Figure 4. In Figure 4, an MCM 24, which measures about 10 mm square, is shown mounted on the die attach pad 13 formed in the upper metallisation layer 30 of the BGA package 10. The BGA package 10 measures 10 approximately 17 mm along each side, leaving approximately 3 mm each side for the wire-bond pads 20 and the seal ring 21. A large number (in this case, 121) of solder balls 22 is distributed throughout the lower metallisation layer 32 as an array, those occupying most of the central area beneath the MCM 24 being allocated to ground and shown designated as "g". The solder ball array is located on solderable metallisation 15 pads, which, in the case of the cofired ceramic package employed in this embodiment, comprise tungsten pads coated with nickel and gold to ensure solderability. The solder balls are confined to the required locations over the lower grounded metallisation layer 32 by the selective deposition of the solderable nickel-plus-gold finish over the otherwise unsolderable tungsten layer, or by the addition of a further, thin, ceramic 20 coating finish over the areas that are not required to be solderable.

Outside the central area of the BGA package, i.e. in the peripheral area, in each corner of the package, are located a group 21 of solder balls 22 which serve to provide

grounding connections for the seal ring 14. Grounding here ensures that a metal lid 21, which is bonded to the seal ring, will act as an electrical screen, helping to exclude RF interference from the circuitry on the MCM.

One group 16 only of wire-bond pads 20 is shown in Figure 4, though it should be understood that there are four such groups in all situated along the four peripheral edge portions of the substrate 12. The wire-bond pads 20 are formed in the upper metallisation layer 30 and are disposed at a uniform pitch of 400 μm , there being 25 such pads in each group. The wire-bond pads on the substrate 40 of the attached MCM 24 may be spaced at a matching pitch to facilitate the use of short (less than 1 mm), parallel and low-inductance wire bonds between the MCM substrate 40 and the BGA package 10. Double or triple bonds may be employed on critical pads for lower inductance, where required.

The wire-bond pads 20 are allocated severally to signal functions and power/ground functions. Power for the MCM is taken from a row of solder balls along and inside each edge of the die attach pad 13. Only one such row is illustrated, containing four power inputs V1-V4, the other three such rows containing further inputs V5-V16. The inputs V1-V4 are fed to their respective wire-bond pads 20 by means of appropriate vias in the dielectric layers 33, 34 and traces in the inner metallisation layer 31, the latter being shown as dotted lines. The remaining wire-bond pads 20 are used as signal connections, and there are fifteen of these signal pads each side, i.e. sixty in all. The input signal connections are taken from the outer two peripheral rows of solder balls, i.e. from balls numbered 1-15, the links to the

corresponding wire-bond pads being, as in the case of the power connections, by appropriate vias and inner traces.

The solder balls are arranged to be approximately 0.6 mm in diameter at an inter-ball pitch of 1.5 mm, approximately. Thus, using the power and signal feed arrangement shown in Figure 4, whereby no pad 20 in the row 16 is linked to a solder ball further away than 1.5 mm, the power and signal connections are guaranteed to possess low resistance and self-inductance, which is essential where the MCM contains circuitry working at very high frequencies.

Most of the signal pads in the wire-bond group 16 (and in the other three groups) are arranged to be disposed between power or ground pads, the effect of this being to minimise crosstalk between signal connections. Thus, signal pad 51 is arranged to lie between a grounded pad 52 and a similar grounded pad 53, the pads 52 and 53 being extensions of the grounded die-attach pad 13. Likewise, signal pad 54 is located between grounded pad 53 and power-supply pad 55, which carries the power line V1. The same applies to most of the signal pads in the group, exceptions being the signal connections numbered 5-9 and 11.

It is also found that the local proximity of the grounded package base metallisation 23 (see Figure 2) and the grounded seal ring structure 14 helps to shield the emerging signal trace connections and maximises isolation.

The bulk of the central area of the BGA package is employed almost exclusively for establishing ground connections with the external circuitry with which the MCM is associated, and therefore no inner-layer traces are required inside this area. The

invention takes advantage of this to incorporate into the inner metallisation layer passive components which function as resonant or filter elements, or as tuning and adjusting elements for the circuitry in the MCM. One such component, shown in Figure 5, is a quarter wavelength resonator, realised in triplate form. The resonator
5 60 consists of a strip 61 of inner metallisation 31 coupled by means of appropriate via routing to one or more wire-bond pads 20 at the, in this case, right-hand edge of the BGA package 10. The resonator relies for its operation on a transmission line effect that exists between the strip 61 and the parallel-lying upper and lower ground planes 13 and 23 (see Figure 2), the three metallisation structures forming then what is known
10 as a triplate structure. The alumina ceramic composing the substrate of the present embodiment has a relative permittivity, ϵ_r , of approximately 9.8 at 2.4 GHz, which means that, if the resonator is to be a quarter-wave resonator at that frequency, it needs to be 10 mm in length. The line width for a 50 ohm impedance triplate structure in the 0.6 mm thick package base illustrated in Figure 2 is about 0.3 mm. The resistance
15 of such a line in a typical inner-layer tungsten metallisation having a resistance of 10 m Ω per square, is about 0.33 ohms. This resistance governs the Q-factor of the resonator.

The area occupied by the resonator 60 is conveniently restricted to those parts of the central area of the BGA package which lie between the solder balls 22, i.e. the
20 strip 61 runs between adjacent rows of solder balls 22, and approximately parallel to them. The 50-ohm width of the resonator, i.e. nominally 0.3-0.4 mm, fits comfortably within the inter-ball pitch, which is approximately 1.5 mm.

Another passive element that may be incorporated into the substrate in the central area is an interdigitated triplate filter. Such a filter structure, which may be employed as a transmit and/or receive chain band-pass filter, for example, is illustrated in Figure 6. In Figure 6, a filter 70 consists of three quarter-wavelength strips 71-73 of inner metallisation 31, each having a width and length similar to that of the resonator 60 in Figure 5 to achieve a 50-ohm impedance, and each co-operating with neighbouring upper and lower metallisation layers to form a triplate transmission line system as in the case of the resonator 60. Again, connections to one end of each of the strips 71-73 are made by way of vias and, where necessary, further traces linking with the wire-bond pads 20, but this time connections are taken from opposite sides of the BGA package 10. Thus, the outer strips 71, 73 are fed from, in this case, the right-hand side of the BGA package, while the centre strip 72 is fed from the left-hand side. Filter tap points may also be placed along the length of the outer filter elements according to the specific design required.

Because a cofired ceramic fabrication process is employed for the BGA package 10 in this embodiment, the dimensional instability inherent in the firing process must be taken into account the dimensions of the resonator or filter elements are calculated. This instability takes the form of shrinkage, typically 16% in linear dimensions with a tolerance of $\pm 0.5\%$. These tolerances lead to similar tolerances in the electrical characteristics of the resonator or filter employed, i.e. its resonant frequency and band-pass characteristics, respectively. In order to achieve tighter tolerances, a combination of triplate and surface microstrip constructions (not shown) are employed to allow

trimming and tuning of these components after manufacture. This is realised by arranging for the majority of the length of a resonator or filter element to be defined in the triplate format described above, but completing the length with the addition of a short length of microstrip formed in the upper or lower metallisation 30, 32. This
5 measure takes part of the element onto the package surface, where laser or abrasive trimming may be employed to adjust the length and resonant behaviour of the line. Care must, however, be taken to ensure that there is minimal discontinuity in the transition between the two formats.

In a second embodiment of a BGA arrangement according to the invention, a
10 PCB-type construction of the substrate is used, rather than a cofired ceramic construction. This employs plated copper metallisation bonded to organic composite laminate materials. Gold wire bonding alone is employed here, in contrast to the gold or aluminium bonding which may be used in the ceramic type of construction. The PCB-type system has the disadvantage that the polymeric materials employed are not
15 as dimensionally stable as the ceramic materials. There is also the fact that alumina ceramic materials can be selected which have very low dielectric loss at the frequencies of interest, whereas dielectric losses in the polymeric materials are likely to be somewhat higher, depending on the level of additives, e.g. fire retardants, incorporated into the laminates involved.

20 On the positive side, however, the PCB-type construction does have the advantage that, since photolithographic methods can be employed to form the necessary

metallisation patterns, these patterns and hence their dimensions can be very accurately controlled.

There is also the advantage that, in such a type of construction, a higher Q-factor may be achieved in the resonator/filter elements incorporated into the body of the BGA package. This is because, firstly, copper is used for the metallisation rather than tungsten, copper having a lower resistivity, and secondly, greater thicknesses of metallisation can be employed in the PCB type of construction than in its ceramic counterpart.

A further difference between the two techniques is that, in the case of the PCB-type construction, the organic polymeric materials used for the substrate have a low dielectric constant. This impinges on the design of a resonator or filter incorporated into the BGA package, and means that both the line width for a 50 ohm impedance and the length of the resonant line has to be increased relative to the cofired substrate case. The increase is of the order of 40%. Because of this, it may be necessary, in a PCB-type construction, to fold the resonator in the plane of the inner metallisation. One such folding arrangement is shown in Figure 7, the folded sections being sections 62-65. Again, each of the sections lies, like the single section 61 in Figure 5, between adjacent rows of solder balls 22. In practice, it may be necessary to widen the distance between the sections in order to avoid unwanted coupling between the turns of the folded structure. This is easily achieved by lengthening the linking sections 62 and 64 and running the parallel sections 63, 65 between more distant rows relative to the section 61.

The above technique of folding the resonator is not restricted solely to the PCB-based arrangement, but may be employed in either construction whenever the length of a resonator or filter element needs to be longer than the central area occupied by the grounded solder balls, for example, because half-wave elements are to be used.

5 The BGA arrangement according to the invention also provides for passive components to be incorporated in the peripheral area, as opposed to the central area. The most convenient part of the substrate for this is that part lying between adjacent groups of wire-bond pads 15-18 (see Figure 1). This is illustrated in greater detail in Figure 4, in which a spiral inductor 81 is shown in the bottom left-hand corner of the
10 package 10. The inductor 81 is conveniently formed in the upper metallisation layer so as to allow maximum spacing between the inductor and the nearby ground plane in the lower metallisation layer, thereby minimising capacitance to ground and maximising the self-resonant frequency of the component. The upper metallisation layer also offers the lowest resistivity in the ceramic construction, since the exposed tungsten
15 metallisation may be overplated with nickel and gold. This, in turn, leads to low inductor resistance and maximum Q-factor.

The inductor 81 may be defined within a 1.2 mm footprint, offering inductance values of up to 11 nH, with Q-factors peaking at between 40 and 80 at around 1 GHz. Such inductors are of particular interest in IF circuitry. A small, laser-trimmable
20 ceramic capacitor 82 may also be mounted adjacent to the inductor 81 to allow, in conjunction with the inductor 81, the tuning of oscillator circuits within the MCM.

The capacitor 82 shown is an 0402 surface-mount component having dimensions 1 mm x 0.5 mm.

Both inductor 81 and capacitor 82 are taken to wire-bond pads 20 and/or solder balls 22 by means of appropriate vias and metallisation traces (not shown).

CLAIMS

1. A ball grid array arrangement, comprising a dielectric multilayer substrate having an upper, a lower and at least one inner layer of metallisation, the lower metallisation layer including an array of solder balls, the substrate having also
5 a central, die-attach area for the mounting of at least one chip or multichip module, and a peripheral area containing bonding structures for establishing electrical connections between at least some of the solder balls and the at least one chip or multichip module, the ball grid array arrangement including a passive circuit element integrated into at least one of the metallisation layers.

10 2. A ball grid array arrangement, as claimed in Claim 1, in which the passive circuit element is formed in the upper or at least one inner metallisation layer within the central area between adjacent rows of solder balls.

3. A ball grid array arrangement, as claimed in Claim 2, in which the passive circuit element is a line resonator, or interdigitated filter, transmission-line
15 structure formed in the at least one inner metallisation layer and defined by that layer in conjunction with adjacent metallisation layers and intervening dielectric layers.

4. A ball grid array arrangement, as claimed in Claim 3, in which the line resonator or interdigitated filter transmission line structure is terminated by a microstrip section formed in the upper or lower metallisation layer, the microstrip section serving

to provide an exposed region of metallisation that can be selectively removed to trim the electrical response of the resonator or filter.

5 5. A ball grid array arrangement, as claimed in Claim 1, in which the peripheral area includes at least two groups of bonding structures, the passive circuit element being disposed in the peripheral area between adjacent groups of bonding structures.

6. A ball grid array arrangement, as claimed in Claim 5, in which the passive circuit element is an inductor.

10 7. A ball grid array arrangement, as claimed in Claim 6, in which the inductor is defined in the upper metallisation layer.

8. A ball grid array arrangement, as claimed in Claim 5 or Claim 6, including a capacitor mounted adjacent to the inductor for providing a tuning function for circuitry within the chip or chip module mounted to the ball grid array arrangement.

15 9. A ball grid array arrangement, as claimed in any preceding claim, including ground planes formed in the upper and lower metallisation layers in the central area, at least some of the solder balls in the lower metallisation layer in the central area being allocated as common ground connections for the ground planes.

20 10. A ball grid array arrangement, as claimed in any preceding claim, including a seal ring disposed around the outer part of the peripheral area, the seal ring serving as a bonding structure for bonding a sealing cover to the ball grid array arrangement.

11. A ball grid array arrangement, as claimed in Claim 10, in which the seal ring is arranged to be grounded by means of solder balls in the lower metallisation layer.
12. A ball grid array arrangement, as claimed in any preceding claim, in
5 which the bonding structures in the peripheral area are wire-bond pads formed in the upper metallisation layer, the pads being either signal pads or ground or power supply pads, the pads being arranged so that at least some of the signal pads are each situated between ground or power supply pads.
13. A ball grid array arrangement, as claimed in Claim 12 and Claim 11, in
10 which the wire-bond pads are disposed between the central ground plane in the upper metallisation layer and the peripheral seal ring.
14. A ball grid array arrangement, substantially as shown in, and as hereinbefore described in connection with, Figures 1 to 7 of the drawings.
15. A multichip module assembly, including a ball grid array arrangement,
15 as claimed in any preceding claim, and a multichip module mounted on the ball grid array arrangement.
16. A multichip module radio or communications device, including a multichip module assembly as claimed in Claim 15.

Relevant Technical Fields

- (i) UK Cl (Ed.M) H1R (RAA,RAB,RBG,RBW,RBX)
- (ii) Int Cl (Ed.5) H05K 1/00,1/02,1/16,1/18,7/00,7/02,7/06

Search Examiner
J Donaldson

Date of completion of Search
24 May 1994

Databases (see below)

(i) UK Patent Office collections of GB, EP, WO and US patent specifications.

Documents considered relevant following a search in respect of Claims :-
1 to 16

(ii) **ONLINE DATABASES : WPI**

Categories of documents

- | | |
|--|---|
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|--|---|

Category	Identity of document and relevant passages	Relevant to claim(s)
NONE		

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